

U. S. Department of Commerce, Patent and Trademark Office	Atty Docket No.	Serial No.
	M-12347 US	10/092,201
INFORMATION DISCLOSURE STATEMENT BY APPLICANT	Applicants	
(Use several sheets if necessary)	Paul E. Brunemeier, Archita Sengupta, Justin F. Gaynor, Robert H. Haveman	
	Filing Date 3/4/02	Group
	10/092,201	172

U.S. Patent Documents

*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
gm	AA	6,329,062 B1	12-11-02	Gaynor	428	447	
gm	AB	6,260,949 B1	7-17-01	Smith, et al.	347	44	
	AC						
	AD						
	AE						
	AF						
	AG						
	AH						
	AI						

Foreign Patent Documents

							Translation	
		Document	Date	Country	Class	Subclass	Yes	No
gm	AJ	9-230600	9-5-97	Japan	H01L	21-30	X	
	AK	2000-199963	7-18-00	Japan	H01L	21-30	X	
	AL	2000-199962	7-18-00	Japan	H01L	21-30	X	

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

gm	AM	Kikkawa, Takamaro. "Proceedings of the International Electronic Devices Meeting," 12-10-13 00, pp. 253-256.
gm	AN	Levy, David. "Electrooptical Devices from Organically Doped sol-Gel Materials," Mol. Cryst. And Liq. Cryst. 1000, Vol. 354, pp. 159-165.
gm	AO	Katz, Alexander and Davis, Mark E., "Molecular imprinting of bull, microporous silica, Nature Vol 403 20 January 2000.
gm	AP	Jalonen, Paavo and Tuominen, Aulis. "The Applicability of Electrodeposited Photoresist in Producing Ultra-fine Lines Using Sputtered Seeding Layers," IEEE 2000 Int'l Symp on Electronic Materials &

gm AQ SzoralZawski, J. et al. "Kinetics of Photochemical Reactions in Condensed Phases, What can be Borrowed from the methods of Dielectric Physics," IEEE, Transactions on Dielectrics and Electrical Insulation VOL 8, NO. 3, June 2001.

Examiner <i>Jeff B. Nohet</i>	Date Considered 12/14/03
*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through	

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